

PCT

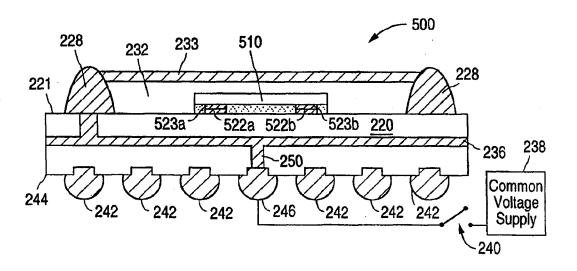
WORLD INTELLECTUAL PROPERTY ORGANIZATION International Bureau



INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification 7: H01L 23/552	A1		International Publication Number: International Publication Date:	WO 00/13233 9 March 2000 (09.03.00)
(21) International Application Number: PCT/US (22) International Filing Date: 23 July 1999 ((81) Designated States: CA, JP, KR, SC CH, CY, DE, DK, ES, FI, FR, NL, PT, SE).	
(30) Priority Data: 09/141,936 28 August 1998 (28.08.98)	τ	JS	Published With international search report	i.
(71) Applicant: AMKOR TECHNOLOGY, INC. [US/USOuth Price Road, Chandler, AZ 85248 (US).	JS]; 19	00		
(72) Inventor: GLENN, Thomas, P.; 1900 South Pr. Chandler, AZ 85248 (US).	ice Roa	ad,		
(74) Agents: PARSONS, James, E. et al.; Skjerven MacPherson, Franklin & Friel LLP, Suite 700, Drive, San Jose, CA 95110 (US).				
			·	

(54) Title: ELECTROMAGNETIC INTERFERENCE SHIELD DEVICE AND METHOD



(57) Abstract

A package for a device includes a substrate having a common voltage plane and a mounting region. The device is mounted to the mounting region. An electrically conductive dam structure is disposed on the upper surface of the substrate circumscribing the perimeter of the mounting region. The electrically conductive dam structure is coupled to the common voltage plane. An electrically insulating encapsulant at least partially fills the pocket defined by the substrate and the electrically conductive dam structure. The electrically insulating encapsulant contacts the electrically conductive dam structure. An electrically conductive encapsulant overlies the electrically insulating encapsulant and is coupled to the electrically conductive dam structure.

FOR THE PURPOSES OF INFORMATION ONLY

Codes used to identify States party to the PCT on the front pages of pamphlets publishing international applications under the PCT.

AL	Albania	ES	Spain	LS	Lesotho	SI	Slovenia
AM	Armenia	FI	Finland	LT	Lithuania	SK	Slovakia
AT	Austria	FR	France	LU	Luxembourg	SN	Seneg al
ΑU	Australia	GA	Gabon	LV	Latvia	SZ	Swaziland
ΑZ	Azerbaijan	GB	United Kingdom	MC	Monaco	TD	Chad
BA	Bosnia and Herzegovina	GE	Georgia	MID	Republic of Moldova	TG	Togo
BB	Barbados	GH	Ghana	MG	Madagascar	TJ	Tajikistan
BE	Belgium	GN	Guinea	MK	The former Yugoslav	TM	Turkmenistan
BF	Burkina Faso	GR	Greece		Republic of Macedonia	TR	Turkey
BG	Bulgaria	HU	Hungary	ML	Mali	TT	Trinidad and Tobago
BJ	Benin	ΙE	Ireland	MN	Mongolia	UA	Ukraine
BR	Brazil	IL	Israel	MR	Mauritania	UG	Uganda
BY	Belarus	IS	Iceland	MW	Malawi	US	United States of America
CA	Canada	IT	Italy	MX	Mexico	UZ	Uzbekistan
CF	Central African Republic	JP	Japan	NE	Niger	VN	Viet Nam
CG	Congo	KE	Kenya	NL	Netherlands	YU	Yugoslavia
CH	Switzerland	KG	Kyrgyzstan	NO	Norway	zw	Zimbabwe
CI	Côte d'Ivoire	KP	Democratic People's	NZ	New Zealand	•	
CM	Cameroon		Republic of Korea	PL	Poland		
CN	China	KR	Republic of Korea	PT	Portugal		
CU	Cuba	KZ	Kazakstan	RO	Romania .		
CZ	Czech Republic	LC	Saint Lucia	RU	Russian Federation		
DE	Germany	LI	Liechtenstein	SD	Sudan		
DK	Denmark	LK	Sri Lanka	SE	Sweden		
EE	Estonia	LR	Liberia	SG	Singapore		

ELECTROMAGNETIC INTERFERENCE SHIELD DEVICE AND METHOD

FIELD OF THE INVENTION

5

10

The present invention relates to packaging technology, and more specifically, to an electromagnetic interference shield package and methods for providing and using the electromagnetic interference shield package.

BACKGROUND OF THE INVENTION

- 15 Electromagnetic interference (EMI) is the impairment of a wanted electromagnetic signal by an electromagnetic disturbance. Each electronic component operates using a flow of charge carriers, the flow inducing a surrounding electromagnetic field. 20 surrounding electromagnetic field may cause sufficient noise within surrounding electronic components that the performance of the surrounding electromagnetic components is degraded. EMI is a particular problem in cellular phones in which an antenna emits radio 25 frequencies (RF) which could affect the other circuitry operating in the phone. In order to isolate an electronic component from EMI, EMI shielding has been recently developed.
- Lin (U.S. Patent No. 5,436,203) discusses an EMI shielded device. Fig. 1 is a cross-sectional view of a similar EMI shielded device. In Fig. 1, an electrically insulating encapsulant 38 mechanically protects a semiconductor die 32. The electrically

insulating encapsulant 38 is constrained by a dam structure 40 so as not to encapsulate electrically conductive reference pads 18. Reference pads 18 are electrically connected to the reference plane 22 by electrically conductive vias 20. An electrically conductive encapsulant 42 is dispensed over the first encapsulant and is in contact with the reference pads 18. The electrically conductive encapsulant 42 is constrained by a second dam structure 44.

10

25

The shielding of device 32 requires the fabrication of two separate dam structures 40 and 44. This requires two separate process steps, one step for the deposition of each dam structure 40 and 44.

15 Furthermore, the size of the package 30 is much larger than the size of the device 32 because a dam structure 40 must surround device 32 while a separate dam structure 44 surrounds the dam structure 40. This double dam structure results in a large footprint of 20 package 30 on a printed circuit board.

It is desirable to reduce the number of process steps in packaging a semiconductor device. It is also desirable to reduce the package size relative to the device size.

SUMMARY OF THE INVENTION

In accordance with the present invention, a package for a device is described. The package includes a substrate having a common voltage plane and a mounting region. The device is mounted to the mounting region. An electrically conductive dam

structure is disposed on the upper surface of the substrate. The electrically conductive dam structure is electrically coupled to the common voltage plane and circumscribes a perimeter of the mounting region. An electrically insulating encapsulant at least partially fills a pocket defined by the substrate and the electrically conductive dam structure. The electrically insulating encapsulant contacts the electrically conductive dam structure. An electrically conductive encapsulant overlies the electrically insulating encapsulant and is coupled to the electrically conductive dam structure.

The package in accordance with the present

invention shields the device from EMI such as radio
frequency ("RF") interference using only one dam
structure. Since a double dam structure of the prior
art uses an additional dam structure surrounding a
primary dam structure, the package of the present

invention is substantially smaller (e.g., by 10 to 20
percent or more) compared to the double dam structure
package of the prior art.

In accordance with the present invention, a method of packaging a device is described as follows. The method includes providing a substrate having a common voltage plane and a mounting region. The device is mounted to the mounting region. The method includes providing an electrically conductive dam structure disposed on the upper surface of the substrate. The electrically conductive dam structure is electrically coupled to the common voltage plane and circumscribes a perimeter of the mounting region. The method includes providing an electrically insulating encapsulant which

5

at least partially fills a pocket defined by the substrate and the electrically conductive dam structure. The electrically insulating encapsulant contacts the electrically conductive dam structure. The method includes providing an electrically conductive encapsulant that overlies the electrically insulating encapsulant and which is coupled to the electrically conductive dam structure.

- The method of fabricating in accordance with the present invention results in an EMI shield device in which only one dam structure is fabricated. The number of dam structures in the conventional double dam structure package may be two. Each dam structure deposition requires a separate process step.

 Therefore, the method of the present invention reduces the number of steps required to fabricated an EMI shield device.
- 20 In accordance with the present invention, a method of using a package includes applying a common voltage to the common voltage plane. A context for the common voltage plane is as follows. The device is mounted to a mounting region of the substrate. An electrically 25 conductive dam structure is disposed on the surface of the substrate around a periphery of the mounting region. The electrically conductive dam structure is electrically coupled to the common voltage plane. electrically insulating encapsulant at least partially fills a pocket defined by the substrate and the 30 electrically conductive dam structure. An electrically conductive encapsulant overlies the electrically insulating encapsulant. The electrically conductive

encapsulant being electrically coupled to the electrically conductive dam structure.

The method of using the device in accordance with the present invention allows for the use of a device that is EMI shielded and is smaller than conventional EMI shielded devices.

These and other objects, features and advantages
of the present invention will be more readily apparent
from the detailed description of the various
embodiments set forth below taken in conjunction with
the accompanying drawings.

15

BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a cross-sectional view of an EMI shielded device in accordance with the prior art.

- Fig. 2 is an isometric view of a package having a device mounted to a surface of a substrate during packaging in accordance with the present invention.
- 25 Fig. 3 is an isometric view of the package of Fig. 2 having an electrically conductive dam structure dispensed around a periphery of the device to define a pocket with the substrate.
- Fig. 4 is a cross-sectional view of the package of Fig. 3 along cross-section line 4-4 of Fig. 3.

Fig. 5 is a cross-sectional view of a package having a flip chip mounted device in accordance with the present invention.

5

10

15

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

Several elements in the following figures are substantially similar. Therefore similar reference numbers are used to represent substantially similar elements.

Fig. 2 is an isometric view of a package 200 having a device 210 mounted to an upper surface 221 of a substrate 220 during packaging in accordance with the present invention. Device 210 may be a semiconductor die which may contain circuitry sensitive to EMI.

Substrate 220 has contact regions, such as bond 20 pads 222a and 222b, formed on upper surface 221. Device 210 has corresponding contact regions, such as bond pads 223a and 223b, coupled to circuitry (not shown) within device 210. Leads, such as bond wires 224a and 224b, electrically couple bond pads 223a and 223b to respective bond pads 222a and 222b. Bond pads 25 222a and 222b are electrically coupled to corresponding solder balls 242 (Fig. 4) on the lower surface 244 of substrate 220 (Fig. 4). Alternatively, device 210 is electrically connected to substrate 220 in a leadless fashion such as is described in detail hereinafter with 30 reference to Fig. 5.

Substrate 220 has a common voltage contact region, such as a ground via surface 225, on upper surface 221.

Ground via surface 225 may be connected to a common voltage plane, such as a ground plane 236.

Fig. 3 is an isometric view of package 200 having 5 an electrically conductive dam structure 228 dispensed around a periphery of device 210 to define a pocket 230 with substrate 220. Electrically conductive dam structure 228 may be deposited as a high viscosity liquid around the perimeter of device 210 using, for 10 example, a dispense system such as an MRSI 375-3S dispenser produced by MRS Technology, Inc., located at 10 Elizabeth Drive, Chemlsford, Massachusetts. Electrically conductive dam structure 228 circumscribes device 210, bond pads 222a and 222b and bond wires 224a and 224b. Electrically conductive dam structure 228 is 15 disposed over, and in contact with, ground via surface 225.

composed of an electrically conductive material such as, for example, an epoxy resin with electrically conductive fillers. The electrically conductive fillers may be, for example, carbon (approximately 5% by weight of the resin compound) and silver

(approximately 20% by weight of the resin compound) Such an epoxy resin with conductive fillers may be supplied by Dexter Electronics Materials, 9938 Via Pasar, San Diego, 92126 under material identification number QMIDW1193-588.

30

However, one skilled in the art will recognize that the filler to resin weight ratio may be altered to obtain a desired electrically conductivity. For example, the filler to resin weight ratio may vary from

5% or less to 50% or more. Package 200 also includes other packaging elements that are not shown in Fig. 3 for clarity. These packaging elements are shown and described with reference to Fig. 4.

5

Fig. 4 is a cross-sectional view of package 200 along cross-section line 4-4 of Fig. 3. Ground via 227 connects ground via surface 225 to ground plane 236. An electrically insulating encapsulant 232 (e.g., epoxy) is deposited within the pocket 230 defined by the electrically conductive dam structure 228 and substrate 220 using, for example, an MRSI 375-3S dispense system. The electrically insulating encapsulant 232 at least partially fills the pocket such that device 210 and bond wires 224a and 224b are mechanically supported, protected, and electrically insulated.

An electrically conductive encapsulant 233 covers

the electrically insulating encapsulant 232 and is
electrically connected to electrically conductive dam
structure 228. The electrically conductive encapsulant
233 is deposited, using, for example, the MRSI 375-3S
dispense system, such that the electrically conductive
encapsulant 233 is electrically coupled to electrically
conductive dam structure 228. The electrically
conductive encapsulant may be of a material similar to
electrically conductive dam structure 228 and may be of
such a thickness that the sheet resistance is
approximately 1000 ohms/cm².

During operation of device 210, a common voltage supply, such as ground, may be optionally coupled to ground plane 236. This optional coupling is

represented by a switch 240 being closed. However, during packaging, the voltage level on ground plane 236 may also float (switch 240 is open). The common voltage supply 238 is connected to ground plane 236, as shown in Figs. 4 and 5, through a via 250. Via 250 electrically connects the ground plane 236 to solder ball 246, which acts as an input pin for the voltage supplied by common voltage supply 238. Ground plane 236, ground via 227, electrically conductive dam structure 228, and electrically conductive encapsulant 233 are all at a common voltage (either by floating or being coupled to the common voltage supply 238) and substantially encapsulate device 210. Device 210 is thus substantially shielded from EMI.

15

20

25

Fig. 5 is a cross-sectional view of a package 500 having a flip chip mounted device 510 in accordance with the present invention. Package 500 is structured similar to package 200 of Figs. 2-4 except that a flip chip mounted device 510, not adhesively attached and wire bonded device 210, is mounted to upper surface 221 of substrate. Bond wires 224a and 224b are absent because flip chip mounted device 510 has terminals 523a and 523b directly connected to terminals 522a and 522b on substrate 220. Terminals 522a and 522b are electrically coupled to corresponding solder balls 242 on the lower surface 244 of substrate 220.

A method of manufacturing package 200 is now described. The steps described below are not chronologically related to each other unless expressly described below.

Device 210 is mounted to a mounting region 254

(Fig. 4) of substrate 220. The "mounting region" is defined as the region to which device 210 has been, or is to be, mounted. Electrically conductive dam

5 structure 228 is deposited around the outer periphery of mounting region 254. After electrically conductive dam structure 228 is deposited, electrically conductive dam structure 228 may be exposed to ultra violet light (e.g., 310 nanometers wavelength) until electrically conductive dam structure dam structure 228 is gelled.

After device 210 is mounted and electrically conductive dam structure 228 is deposited, electrically insulating encapsulant 232 is deposited into pocket 230 so as to at least partially fill pocket 230 and so as to cover bond wires 224a and 224a and device 210. After depositing the electrically insulating encapsulant 232, electrically insulating encapsulant 232 may also be gelled by, for example, exposure to ultra violet light for 30 seconds.

After, electrically conductive dam structure 228 and electrically insulating encapsulant 232 are deposited, electrically conductive encapsulant 233 is deposited over electrically insulating encapsulant 232 in such a way that electrically conductive encapsulant 233 is electrically coupled to electrically conductive dam structure 228.

Electrically conductive dam structure 228, electrically insulating encapsulant 232 and electrically conductive encapsulant 233 may be cured after depositing electrically conductive encapsulant 233. Curing may occur by exposure to a temperature of

approximately 80 degrees Celsius for 20 minutes followed by exposure to a temperature of approximately 150 degrees Celsius for 40 minutes. Package 500 of Fig. 5 is made using substantially the same technique as described above in reference to package 200 of Fig. 4, except that device 510 of Fig. 5 is mounted to substrate 220 using a flip chip interconnection.

The above described packages 200 and 500 have only 10 one dam structure compared to the two of the conventional double dam structure package. This eliminates the need to have a separate processing step for depositing a second dam structure. Therefore, the number of processing steps to package device 210 (or 510) is reduced compared to the conventional double dam 15 structure package. Furthermore, the size of the package 200 (or 500) is reduced compared to the double dam structures of the prior art EMI shielding package because a second dam structure is not deposited around 20 electrically conductive dam structure 228. reduces the size of the package (e.g., by 10 to 20% or more) compared to the double dam structure package.

Having thus described the various embodiments,

25 persons skilled in the art will recognize that changes
may be made in form and detail without departing from
the spirit and scope of the invention.

For example, although one ground via 227 is

described, two or more ground vias will suffice. Even
zero ground vias are sufficient if the electrically
conductive encapsulant 233 or electrically conductive
dam structure 228 is independently coupled to a common
voltage supply. Zero ground vias are also sufficient

if the dam structure 228 is not coupled to a voltage supply, but is permitted to float.

Although only one device 210 is shown

5 circumscribed by electrically conductive dam structure
228, two or more devices may be circumscribed by
electrically conductive dam structure 228 to be EMI
shielded. Although only two leads, bond wires 224a and
224b, are described, device 210 may have many more
10 leads.

Thus the invention is limited only by the following claims.

CLAIMS

I Claim:

5 1. A package for a device, the package comprising:

a substrate including a common voltage plane and a mounting region, the device mounted to the mounting region;

an electrically conductive dam structure disposed on a surface of the substrate, the electrically conductive dam structure electrically coupled to the common voltage plane and circumscribing a perimeter of the mounting region;

an electrically insulating encapsulant at least partially filling a pocket defined by the substrate and the electrically conductive dam structure, the electrically insulating encapsulant contacting the electrically conductive dam structure; and

an electrically conductive encapsulant overlying the electrically insulating encapsulant, the electrically conductive encapsulant coupled to the electrically conductive dam structure.

- 2. The package of Claim 1, wherein the electrically conductive encapsulant comprises an epoxy with electrically conductive fillers.
- 30 3. The package of Claim 2, wherein the electrically conductive fillers comprise 5 to 50 weight percent of the electrically conductive encapsulant.

4. The package of Claim 3, wherein the electrically conductive fillers comprise approximately 25 weight percent of the electrically conductive encapsulant.

5

5. The package of Claim 1, wherein the substrate further includes electrically conductive vias coupling the electrically conductive dam structure to the common voltage plane.

10

- 6. The package of Claim 5, wherein the common voltage plane is a ground plane coupled to ground.
- 7. The package of Claim 1, wherein the common voltage plane is a ground plane coupled to ground.
- 8. The package of Claim 1, wherein the common voltage plane, the electrically conductive dam structure, and the electrically conductive encapsulant are electrically coupled to a common voltage.
 - 9. The package of Claim 8, wherein the common voltage plane, the electrically conductive dam structure, and the electrically conductive encapsulant shield the device from electromagnetic interference.
 - 10. The package of Claim 1, wherein the common voltage plane is coupled to an electrically conductive ball in a lower surface of the substrate.

30

25

11. The package of Claim 1, wherein the substrate includes a contact region coupled to an electrically conductive ball in a lower surface of the substrate,

the contact region being electrically coupled to circuitry within the device.

12. The package of Claim 11, wherein the contact region is directly connected to a terminal disposed within the device.

13. A method of packaging a device comprising:

providing a substrate including a common

voltage plane and a mounting region, the device

mounted to the mounting region;

providing an electrically conductive dam structure disposed on the surface of the substrate, the electrically conductive dam structure electrically coupled to the common voltage plane and circumscribing a perimeter of the mounting region;

providing an electrically insulating encapsulant at least partially filling a pocket defined by the substrate and the electrically conductive dam structure, the electrically insulating encapsulant contacting the electrically conductive dam structure; and

providing an electrically conductive encapsulant overlying the electrically insulating encapsulant, the electrically conductive encapsulant coupled to the electrically conductive dam structure.

10

15

20

15. The method of Claim 14, further comprising: providing a fixed voltage on the common voltage plane.

5

16. The method of Claim 15, wherein providing a fixed voltage comprises:

grounding the common voltage plane.

17. The method of Claim 13, wherein providing an electrically conductive dam structure on the substrate comprises depositing an electrically conductive epoxy compound in the form of a dam structure on the substrate.

15

- 18. The method of Claim 17, wherein providing an electrically insulating encapsulant comprises, depositing an insulating epoxy within the pocket defined by the device, the substrate and the electrically conductive dam structure.
- 19. The package of Claim 1 wherein there is no additional dam structure for containing the electrically conductive encapsulant.

25

20

20. The package of Claim 1 wherein the dam structure is in contact with a perimeter of the electrically conductive encapsulant.

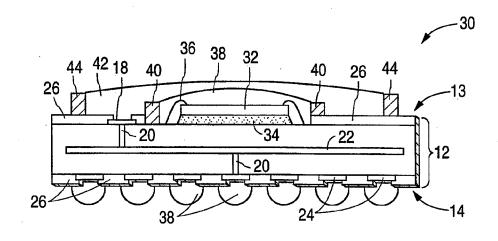


FIG. 1 (PRIOR ART)

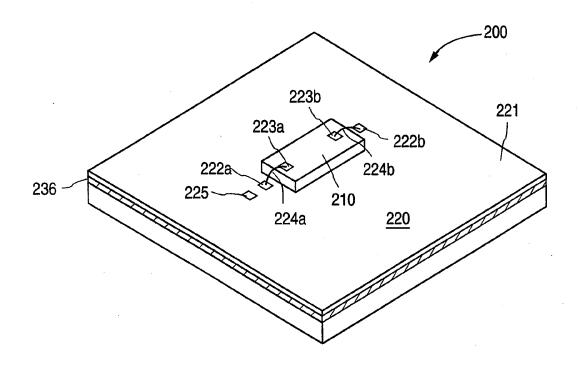
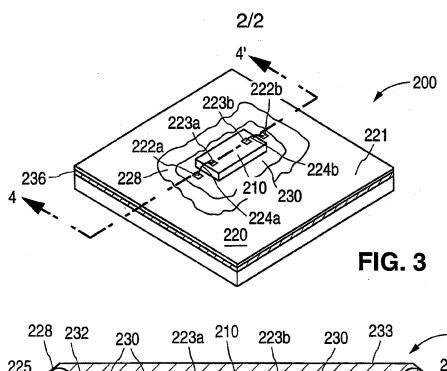
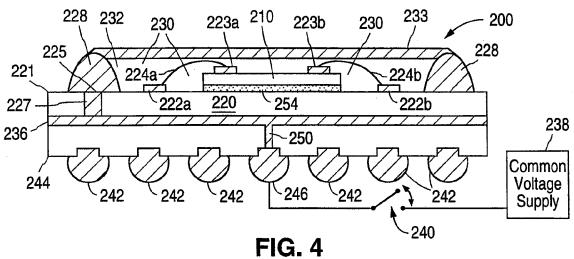
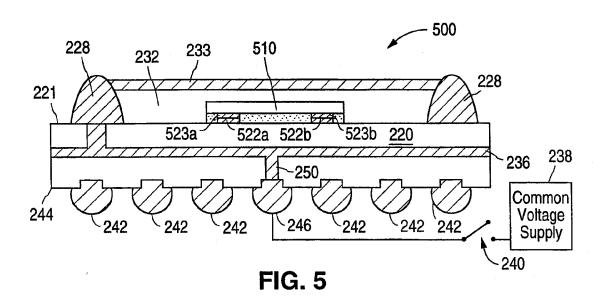


FIG. 2







INTERNATIONAL SEARCH REPORT

interr anal Application No PCT/US 99/16458

A. CLASSIFICATION OF SUBJECT MATTER IPC 7 H01L23/552

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

 $\begin{array}{ll} \mbox{Minimum documentation searched (classification system followed by classification symbols)} \\ \mbox{IPC 7} & \mbox{H01L} \end{array}$

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

C. DOCUMENTS CONSIDERED TO BE RELEVANT					
Category °	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.			
A	US 5 436 203 A (LIN PAUL T) 25 July 1995 (1995-07-25) cited in the application abstract; figure 4 column 2, line 33 - line 61	1-20			
A	US 5 371 404 A (JUSKEY FRANK J ET AL) 6 December 1994 (1994-12-06) abstract; figures 1,2	1-20			
Α	WO 97 25847 A (WIKSTROEM BO ;XICON AB (SE)) 17 July 1997 (1997-07-17) abstract; claims 1-4	1,2,5-9, 13-17			
Α	US 5 639 989 A (HIGGINS III LEO M) 17 June 1997 (1997-06-17) abstract; figure 1 column 7, line 14 - line 67	1-9, 13-19			
	-/				

X Further documents are listed in the continuation of box C.	"T" later document published after the international filling date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art. "&" document member of the same patent family				
"A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier document but published on or after the international filling date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filling date but later than the priority date claimed					
Date of the actual completion of the international search	Date of mailing of the international search report				
5 October 1999	14/10/1999				
Name and mailing address of the ISA	Authorized officer Le Meur, M-A				
European Patent Office, P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl, Fax: (+31-70) 340-3016					

Form PCT/ISA/210 (second sheet) (July 1992)

INTERNATIONAL SEARCH REPORT

Interr onal Application No
PCT/US 99/16458

		PC1/US 99	99/16458		
	ation) DOCUMENTS CONSIDERED TO BE RELEVANT		To the second second		
Category °	Citation of document, with indication, where appropriate, of the relevant passages		Relevant to claim No.		
A	US 5 656 857 A (KISHITA YOSHIHIRO) 12 August 1997 (1997-08-12) abstract; figures 6,8 column 2, line 27 - line 50		1,2,13, 14,17		
A	PATENT ABSTRACTS OF JAPAN vol. 199, no. 813, 30 November 1998 (1998-11-30) & JP 10 214923 A (FUJITSU DENSO LTD), 11 August 1998 (1998-08-11) abstract		1,3		
A	PATENT ABSTRACTS OF JAPAN vol. 10, no. 179, 24 June 1986 (1986-06-24) & JP 61 029158 A (HITACHI LTD), 10 February 1986 (1986-02-10) abstract		1,3		
	·				

Form PCT/ISA/210 (continuation of second sheet) (July 1992)

INTERNATIONAL SEARCH REPORT

..ormation on patent family members

Intern mal Application No PCT/US 99/16458

Patent docume cited in search re		Publication date		atent family member(s)	Publication date
US 5436203	Α .	25-07-1995	NONE	<u></u>	
US 5371404	Α	06-12-1994	EP JP WO	0682812 A 8506695 T 9418707 A	22-11-1995 16-07-1996 18-08-1994
WO 9725847	A	17-07-1997	AU	1325197 A	01-08-1997
US 5639989	Α	17-06-1997	NONE		
US 5656857	Α	12-08-1997	JP	7307416 A	21-11-1995
JP 1021492	3 A	11-08-1998	NONE		
JP 6102915	8 A	10-02-1986	JP JP	1938442 C 6058939 B	09-06-1995 03-08-1994

Form PCT/ISA/210 (patent family annex) (July 1992)